

L Number	Hits	Search Text	DB	Time stamp
-	6246	anneal\$3 near20 oxygen	USPAT; US_PGPUB	2004/01/06 19:39
-	4900	anneal\$3 near20 hydrogen	USPAT; US_PGPUB	2004/01/06 19:40
-	1149	(anneal\$3 near20 oxygen) and (anneal\$3 near20 hydrogen)	USPAT; US_PGPUB	2004/01/06 19:30
-	296	((anneal\$3 near20 oxygen) and (anneal\$3 near20 hydrogen)) and (amorphous near3 silicon)	USPAT; US_PGPUB	2004/01/06 19:40
-	245	((anneal\$3 near20 oxygen) and (anneal\$3 near20 hydrogen)) and (amorphous near3 silicon)) and crystal\$3	USPAT; US_PGPUB	2004/01/06 19:31
-	263	((anneal\$3 near20 oxygen) and (anneal\$3 near20 hydrogen)) and (amorphous near3 silicon)) and crystal\$5	USPAT; US_PGPUB	2004/01/06 19:40
-	176	((anneal\$3 near20 oxygen) and (anneal\$3 near20 hydrogen)) and (amorphous near3 silicon)) and crystal\$5) and (TFT (thin near3 film near3 transistor))	USPAT; US_PGPUB	2004/01/06 19:40
-	48762	(anneal\$3 heat\$3) near20 oxygen	USPAT; US_PGPUB	2004/01/06 19:39
-	46553	(anneal\$3 heat\$3) near20 hydrogen	USPAT; US_PGPUB	2004/01/06 19:40
-	8953	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen)	USPAT; US_PGPUB	2004/01/06 19:40
-	922	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen)) and (amorphous near3 silicon)	USPAT; US_PGPUB	2004/01/06 19:40
-	836	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen)) and (amorphous near3 silicon)) and crystal\$5	USPAT; US_PGPUB	2004/01/06 19:40
-	570	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen)) and (amorphous near3 silicon)) and crystal\$5) and (TFT (thin near3 film near3 transistor))	USPAT; US_PGPUB	2004/01/06 19:41
-	34262	(anneal\$3 heat\$3) near20 oxygen	EPO; JPO; DERWENT; IBM_TDB	2004/01/07 13:34
-	25753	(anneal\$3 heat\$3) near20 hydrogen	EPO; JPO; DERWENT; IBM_TDB	2004/01/07 13:34
-	2543	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen))	EPO; JPO; DERWENT; IBM_TDB	2004/01/07 13:34
-	14	((anneal\$3 heat\$3) near20 oxygen) and ((anneal\$3 heat\$3) near20 hydrogen)) and (amorphous near3 silicon)	EPO; JPO; DERWENT; IBM_TDB	2004/01/07 13:36